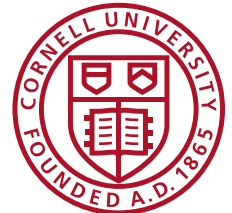
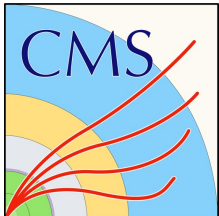
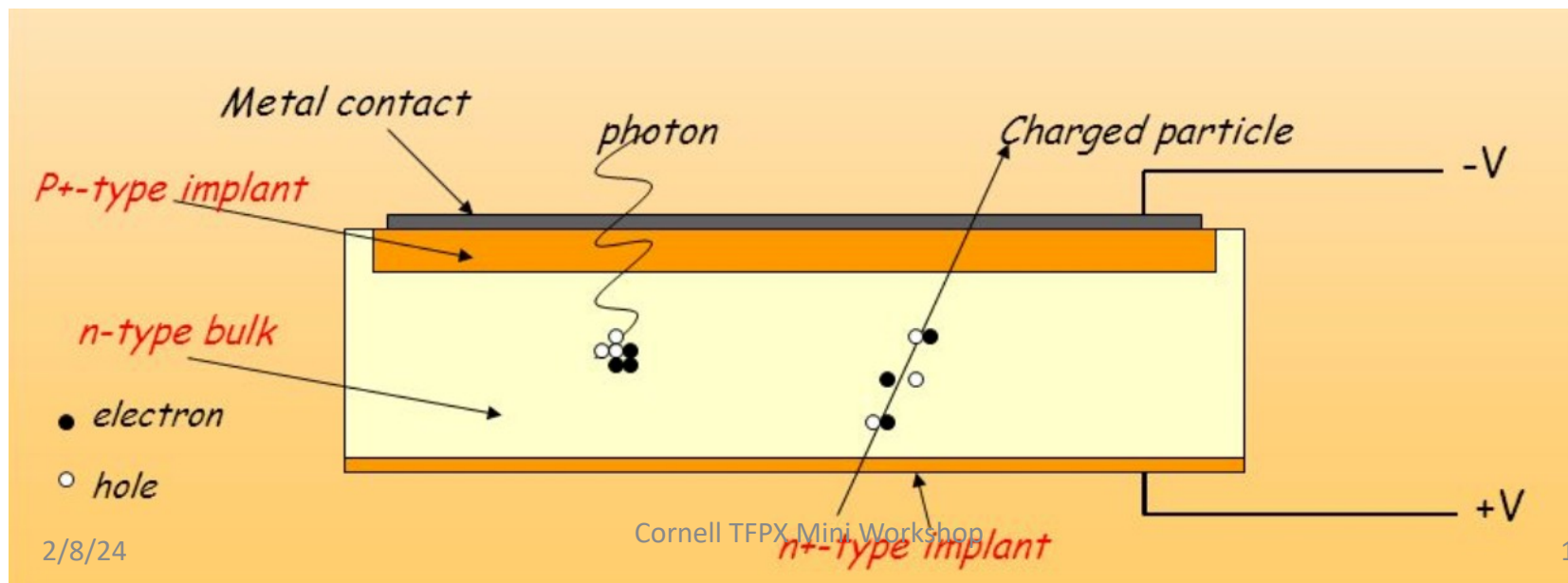


# TFPX Dee Thermal Validation

Xuan Chen

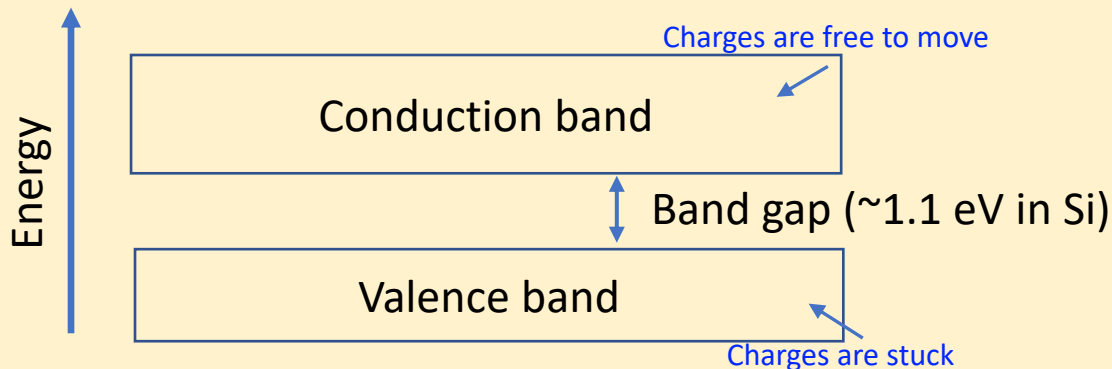


- Thin (150 $\mu\text{m}$ ), planar structures
- diode structure between top and bottom (pin diode)
- (Reverse) bias voltage provides electric field to move signal charges up to collection electrode.
- Plus, thermally-generated reverse current: dark current. Normally *very small*: hence  $\text{Power} = I_{\text{dark}} V_{\text{bias}} = \textit{small}$ .



## Quantum states in semiconductor

Fresh silicon



Thermal energy  $kT$  can kick  $e^-$  into conduction band.  
But  $1/40eV \ll 1.1 eV$

## Quantum states in semiconductor

After radiation damage



Damage to crystal, Si atoms out of place.  
New quantum states appear in bandgap  
→ Stepping stone path to conduction band  
→ Dark Current increases!!

$$I(T) = \text{const} \times T^2 e^{-(T_A/T)}$$

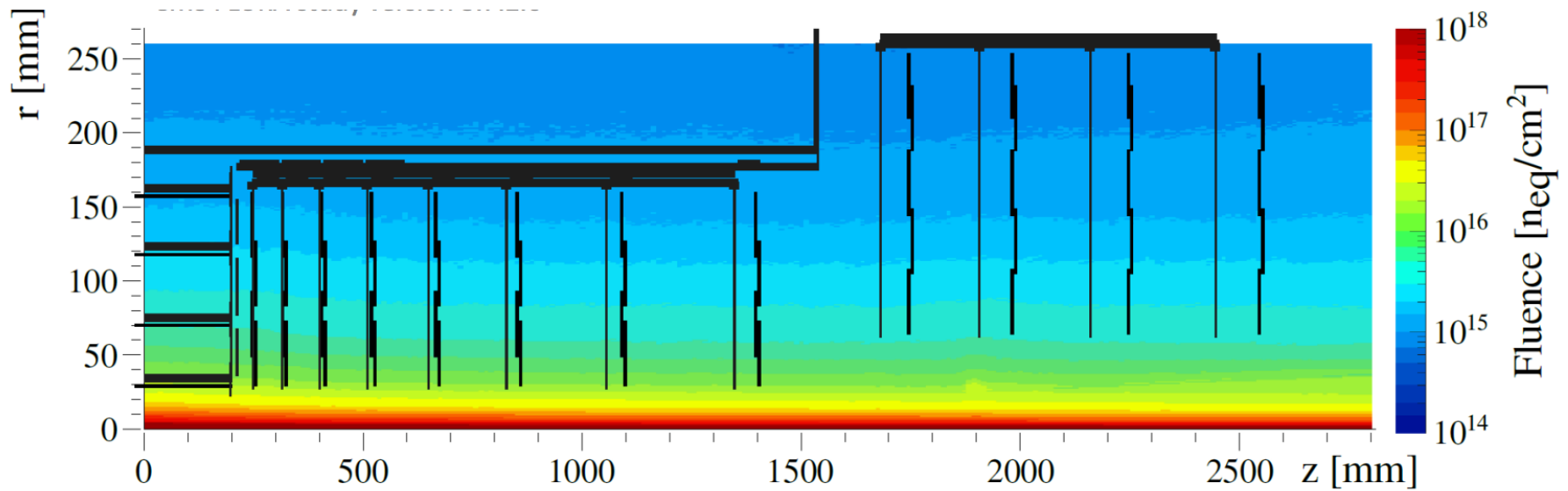
We don't know the constant, but can "calibrate":

$$I(T_{\text{ref}}) = \text{const} \times T_{\text{ref}}^2 e^{-(T_A/T_{\text{ref}})}$$

$$\rightarrow I(T) = I(T_{\text{ref}}) \left( \frac{T}{T_{\text{ref}}} \right)^2 e^{-T_A \left( \frac{1}{T} - \frac{1}{T_{\text{ref}}} \right)}$$

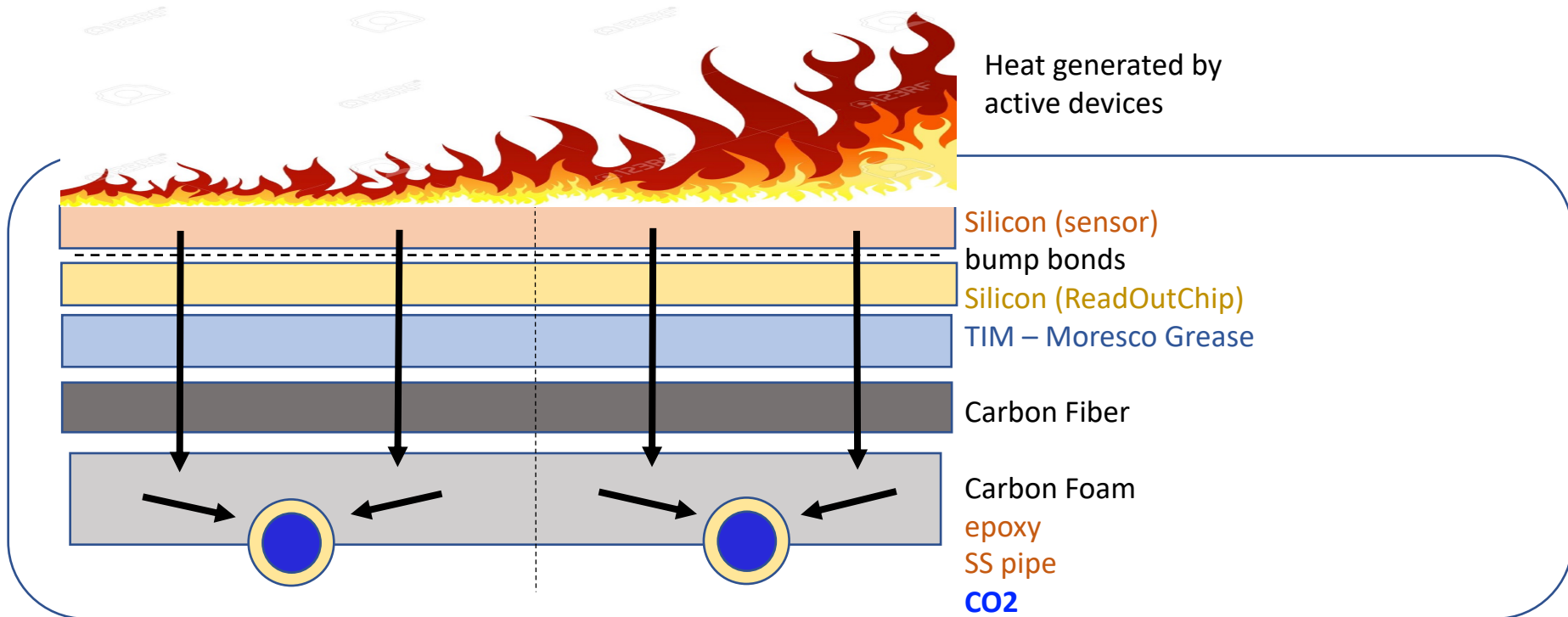
$$Q(T) = I(T_{\text{ref}}) V_{\text{bias}} \left( \frac{T}{T_{\text{ref}}} \right)^2 e^{-T_A \left( \frac{1}{T} - \frac{1}{T_{\text{ref}}} \right)}$$

Heat generated by dark current grows ~exponentially:  
**doubles every 6.5 °C**



Most damage at inner radius – closest to beam

## TFPX simplified model (cross section)



Black arrows show cartoon version of heat flow.

CO<sub>2</sub> is cold! approximately  $T = -33^{\circ}\text{C}$

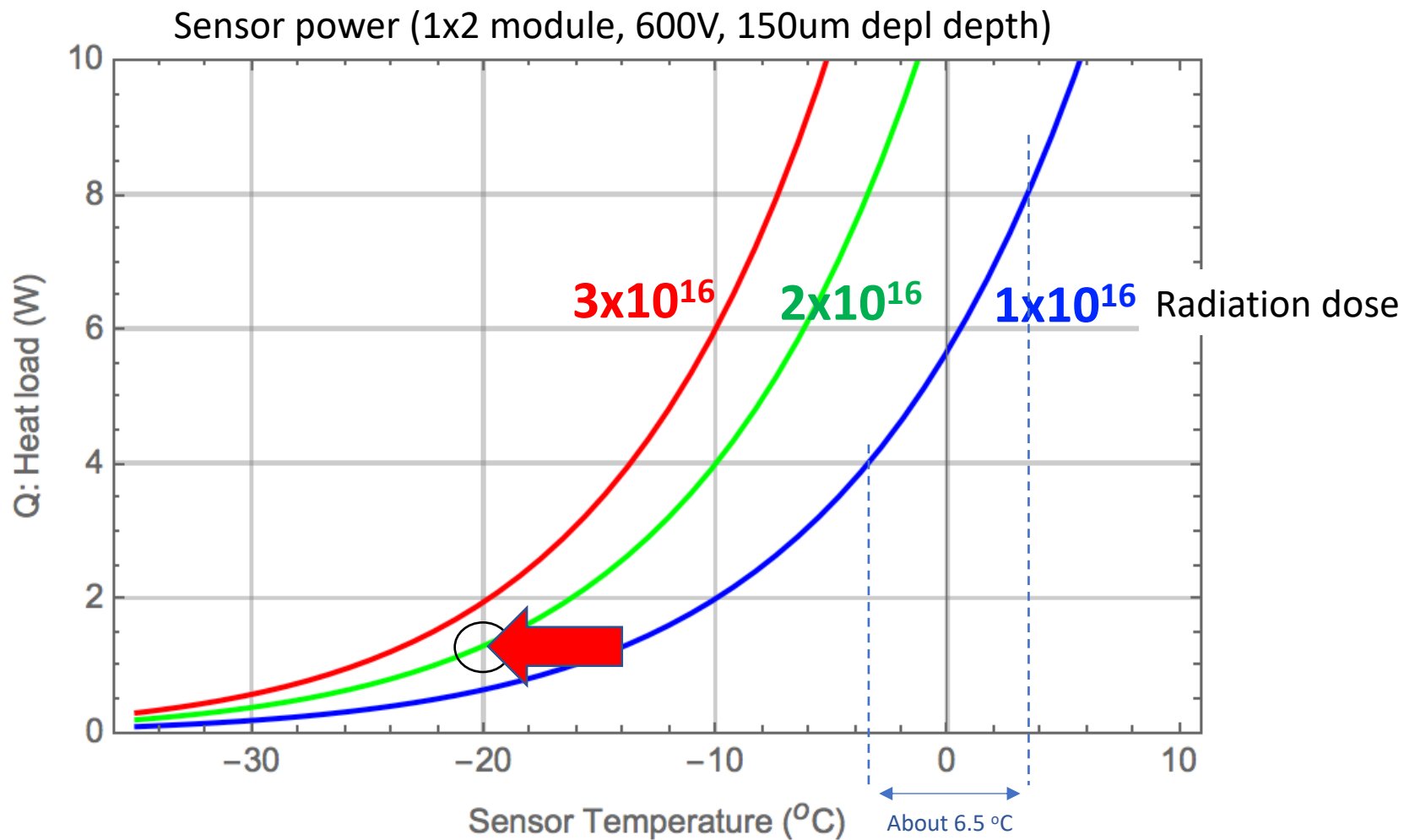


# Where Does the Heat Come From



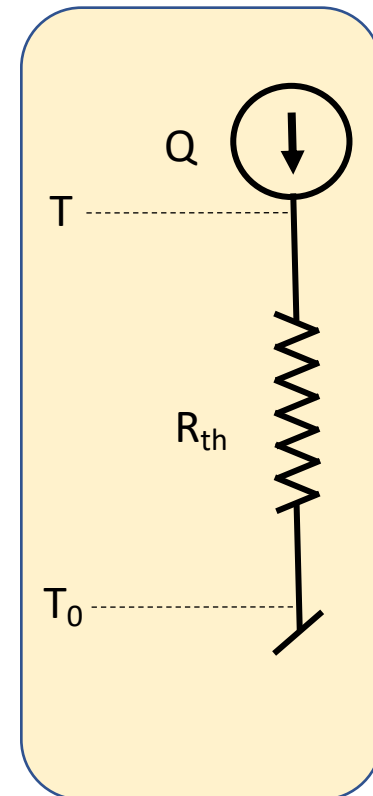
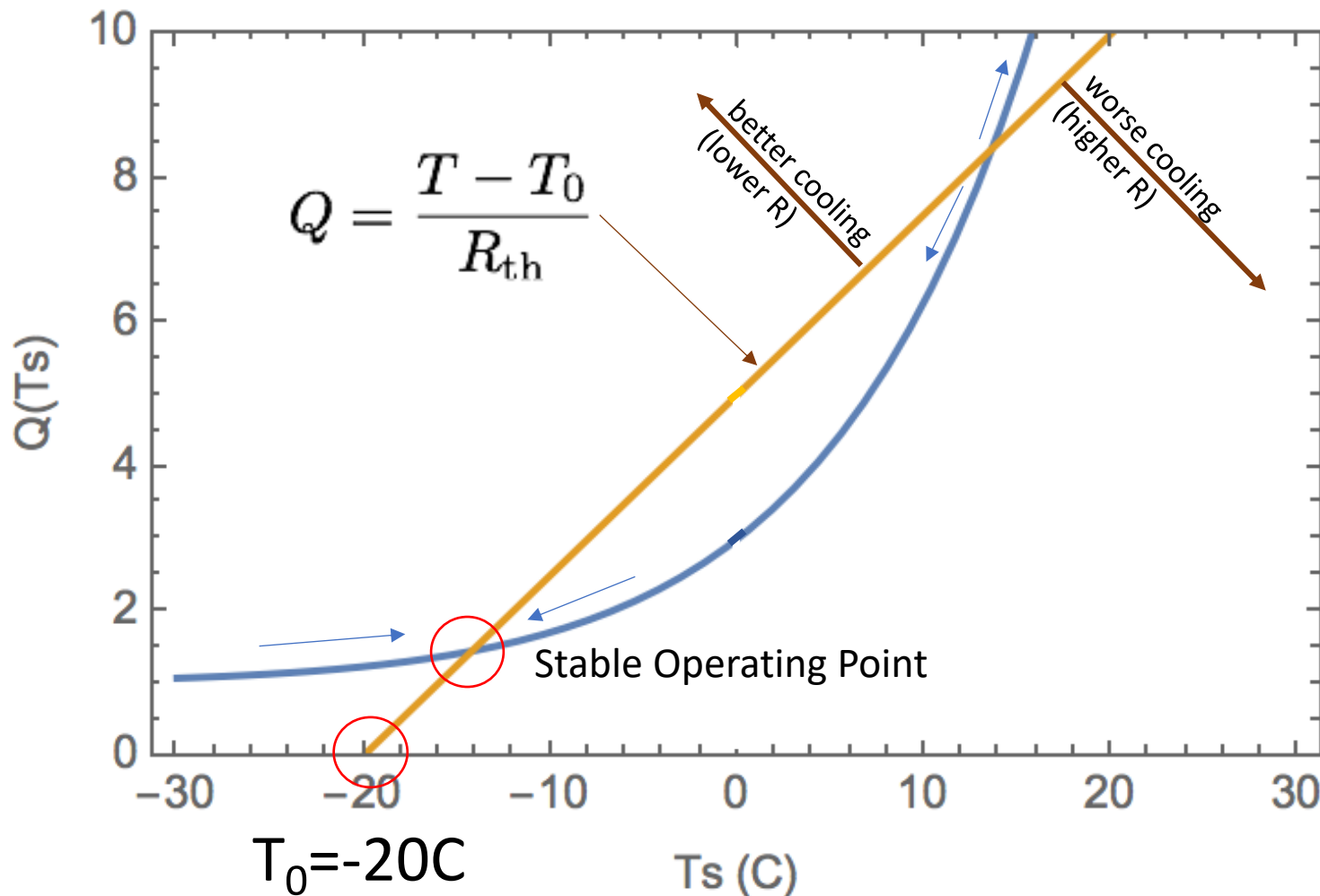
- Electronics for reading out the silicon sensor:
  - Amplifiers, digitization, memory, communication, etc etc.
  - Must be *very fast*:
    - 25ns between proton collisions
    - Extremely large amounts of data to be moved
    - transmission times  $\sim$  tens of GigaBits per second  $\rightarrow$  0.1 ns per bit
  - Fast electronics is hot electronics:
    - changing voltages (eg on transistor gates) requires  $\Delta Q/C = \Delta V$ .
    - fast change  $\rightarrow$   $dV/dt$  is large.  $\rightarrow$   $dQ/dt = I$  is large.  $\rightarrow$   $IV =$  dissipated power, is also large.
    - voltages are low ( $\sim 1.2V$ ) because transistors are small! (65nm). But still...
  - In addition: The ReadOutChip has components that generate lots of heat: Shunt LDOs. These are along side of chip. (hence flames were asymmetric in previous diagram)
- And the silicon sensors also generate some heat.

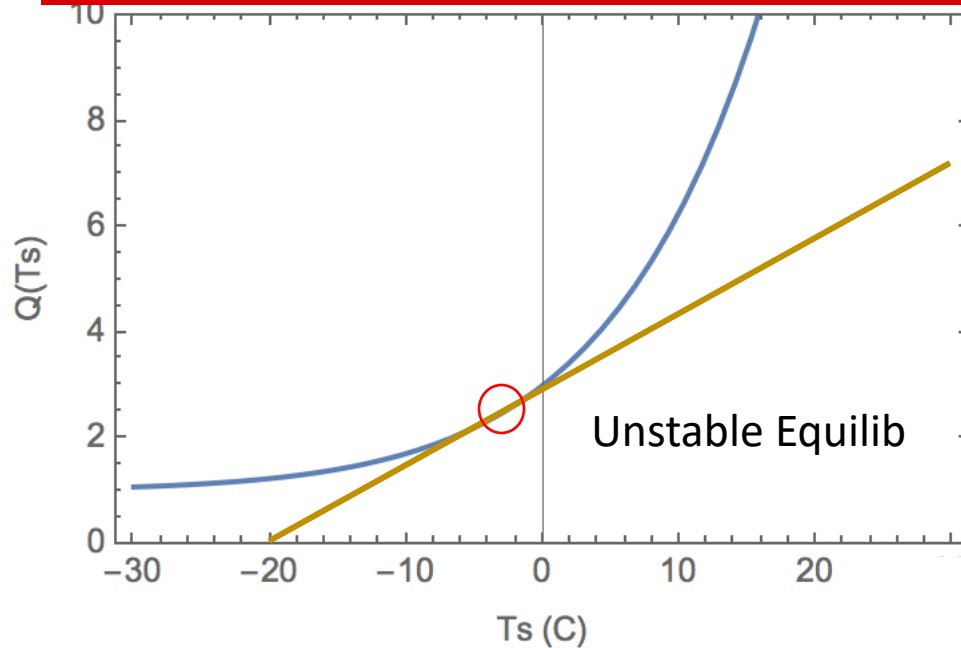
# Exponential Heat Load (Q vs T)





# Cooling is a Linear Process

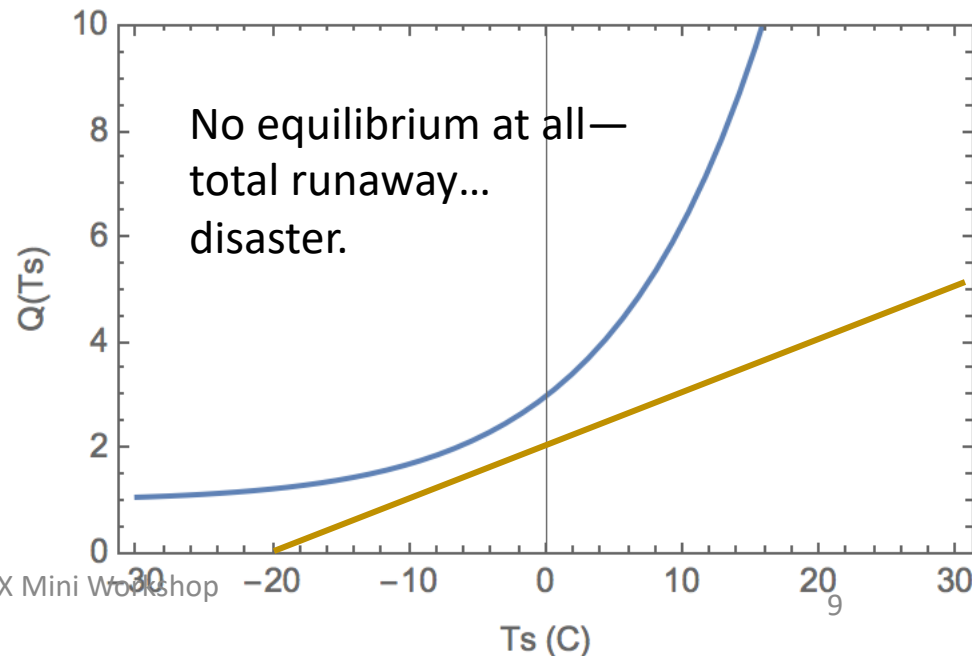




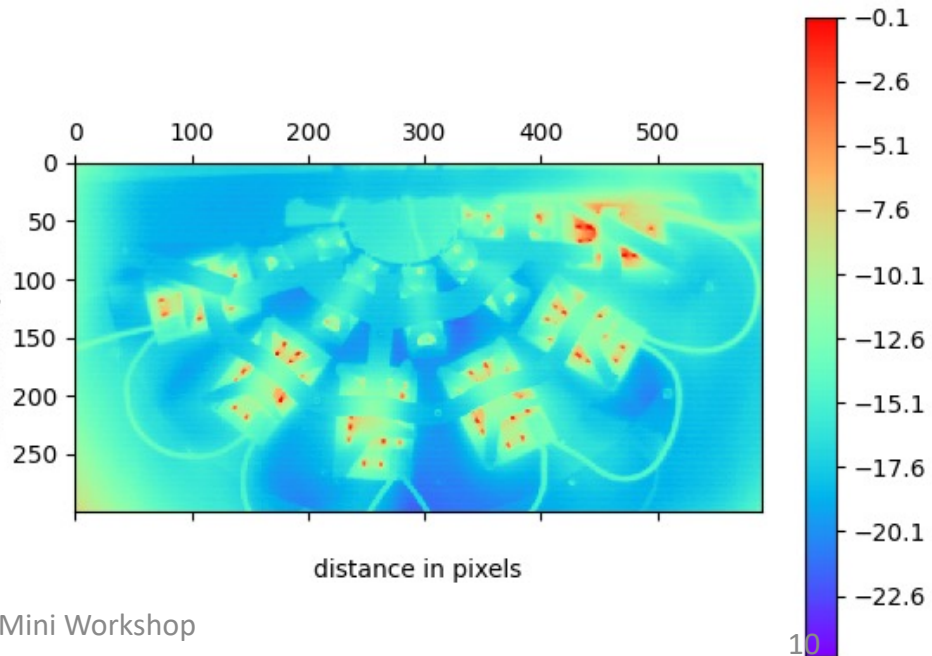
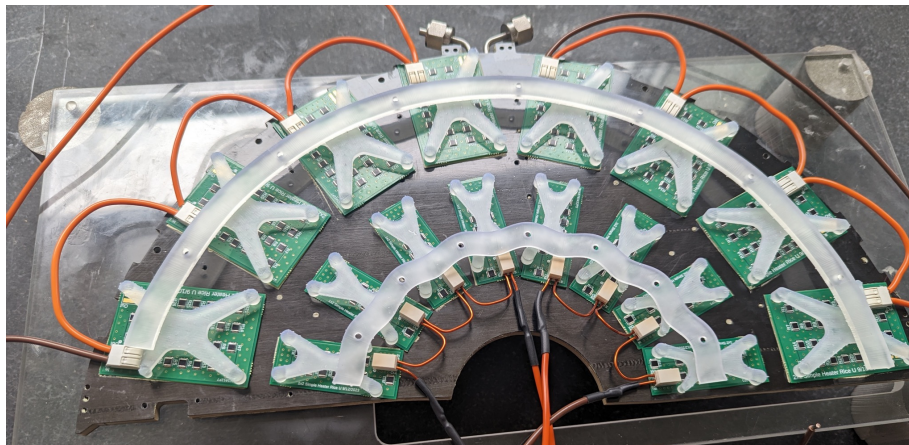
- For a given heat load  $Q$ , there is a minimum thermal resistance  $R$  needed to maintain a stable temp. This “equilibrium” point is unstable!

In both cases,  $R_{th}$  is too high:  
bad design / bad implementation

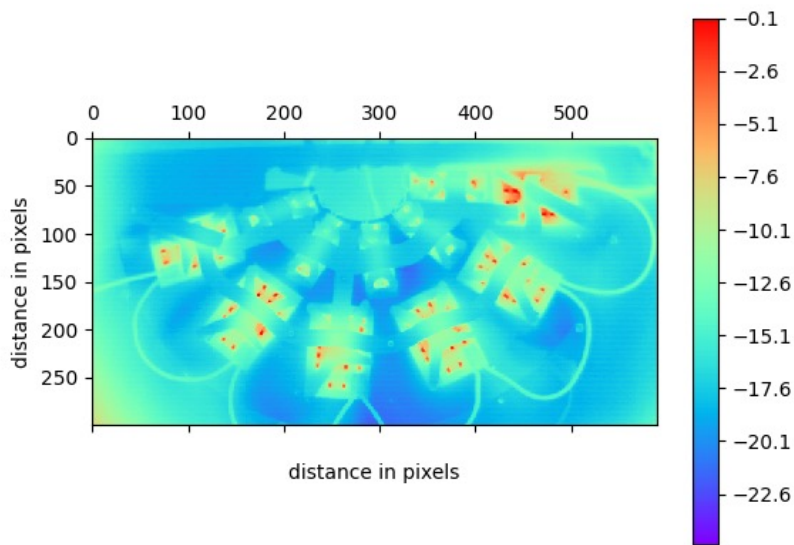
Note:  $T_0$  is same in both cases: this will be our situation since  $T_0 = -33$  C is fixed already by cooling experts.



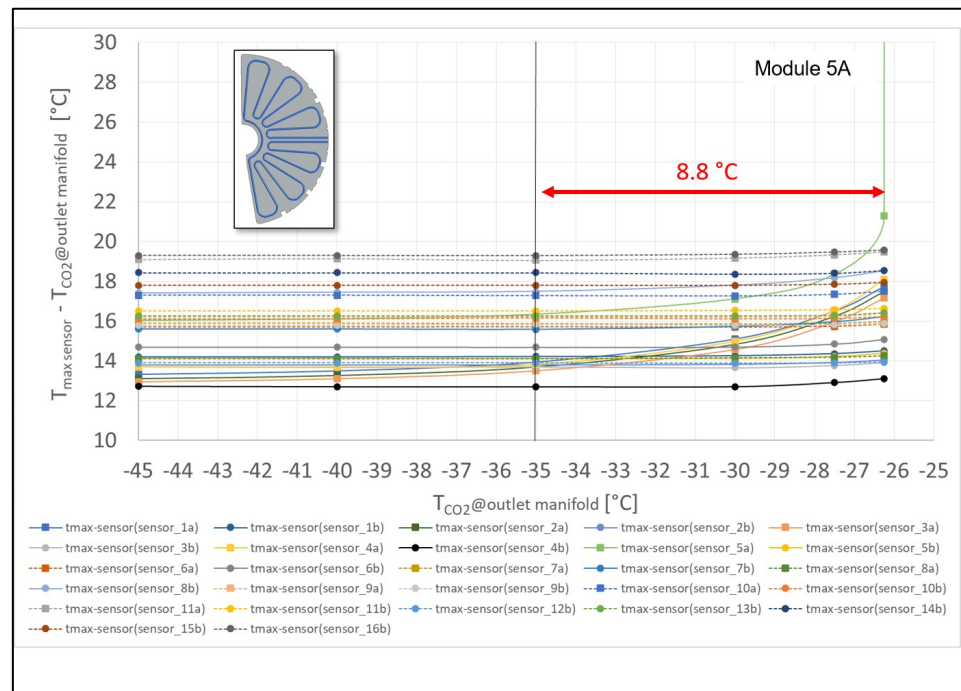
- A full dee thermal test was done on Oct 27<sup>th</sup>, 2023
- The Dee is populated by the PCB heaters on both side
- We used the CO2 plant to cool down the Dee
- The condition of the environment inside the cold box and the cooling line were closely monitored
- The TIM was deposited by hand with a stencil: ~120  $\mu\text{m}$



- Based on the previous simulation, the temperature of the Dee is significantly lower than what we have in our setup



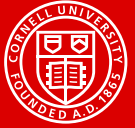
Temperatures w/o dark current in our test



Temperatures with dark current in Ansys simulation



# What's Next



## We need a real Dee

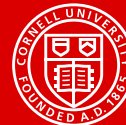
- It is hard for us to make any conclusion without the actual Dee with the current design. In order to make the Dee, we need the following:
  - **The latest carbon fiber**
  - **The new tube**
  - **Gantry applied epoxy**
- **Due to the limitation of the parts, we will conduct our tests on plaquettes for the time being**

## We need to use a more realistic thermal mockup module

- Currently we use the internal NTC data from the pixelalive test as the reference for the temperature of the real module
  - However, **we realized that the internal NTC sometimes gives a random temperature (over 100C) It happens ~once per 5 tests**
  - We can't put RTDs on a real module to calibrate the emissivity
- Using thermal mockup modules can provide more realistic thermal distributions
- In addition, we can also use them as a practice for figuring out how to install real modules



# Summary



- It is very important for us to have a good understanding of the thermal performance of the Dee before we start the production
- We will need all of the newest parts to have conclusive thermal tests and studies
- We will rerun all the tests with plaquette
- We will work closely with the Purdue and Perugia team for the comparison with the simulation